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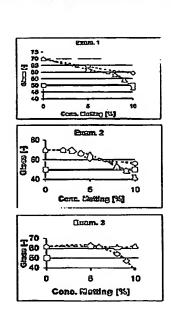
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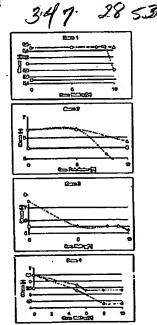
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(54) Title: INKIET INK COMPOSITION EXHIBITING LOW GLOSS





(57) Abstract: Non-visible ink-jet printing ink composition for marking a substrate, comprising at least one marking compound absorbing light outside the visible wavelength range of about 400 - 700 nm, and which comprises a hydrocarbon compound, having two to six carbon atoms carrying two or three hydroxyl groups, as a non-particulate matting agent, so as to adapt the gloss of the ink-jet printed marking to the gloss of the substrate.